

# DESY R&D work related to WG4

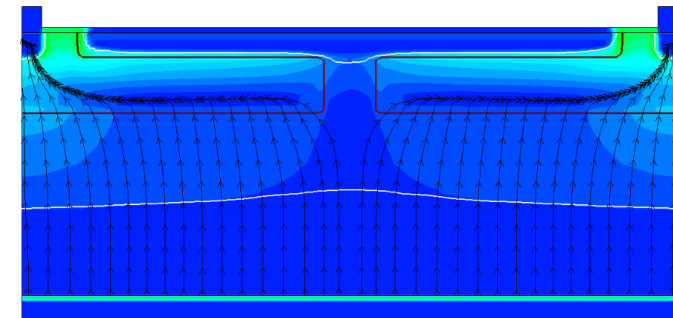
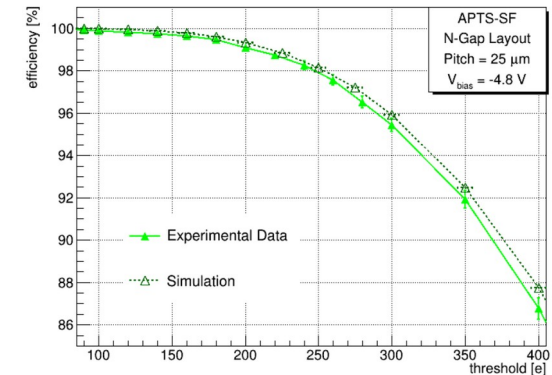
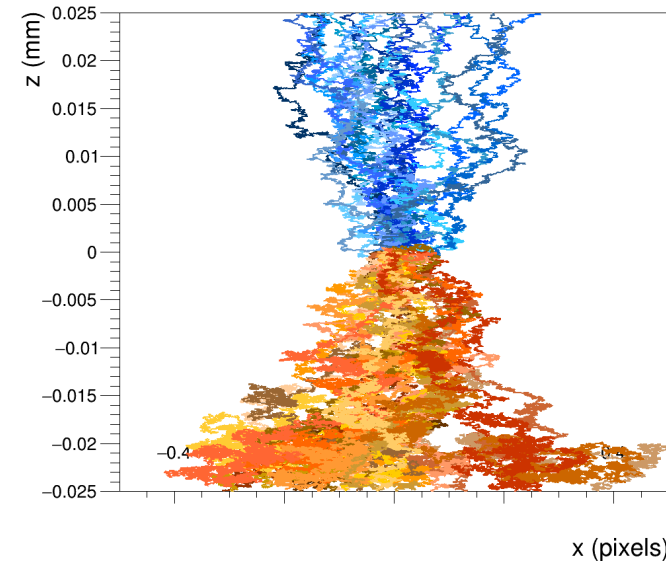
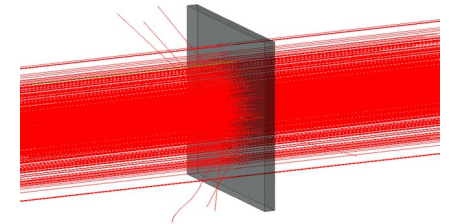
Simon Spannagel

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# General

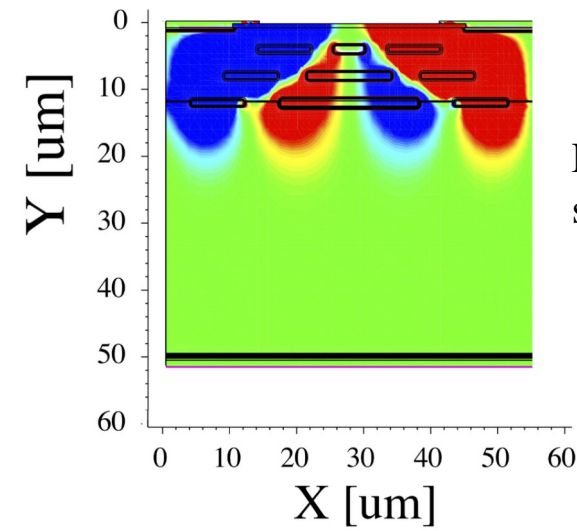
- Simulation work being carried out in
  - Charge generation and transport in semiconductors
  - Monolithic active pixel sensors
  - Strip sensors
  - 3D sensors
  - Front-end electronics response
  - Sensor capacitance
- Development of a simulation toolbox for MAPS simulations, free from proprietary information
- Main development and maintenance of the Allpix Squared simulation framework
- Simulation-guided design of sensor prototypes

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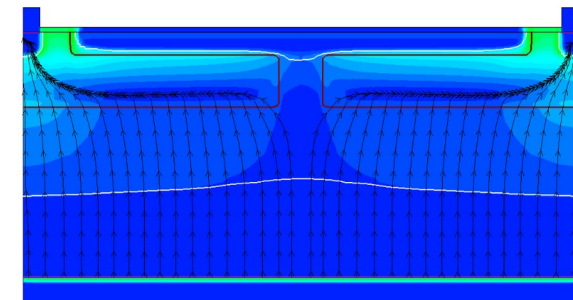
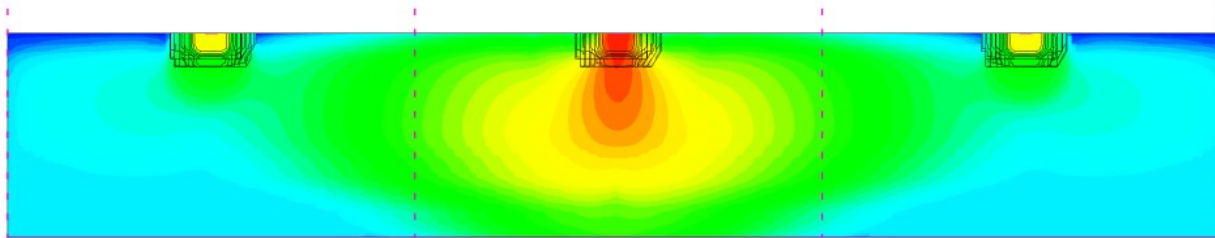
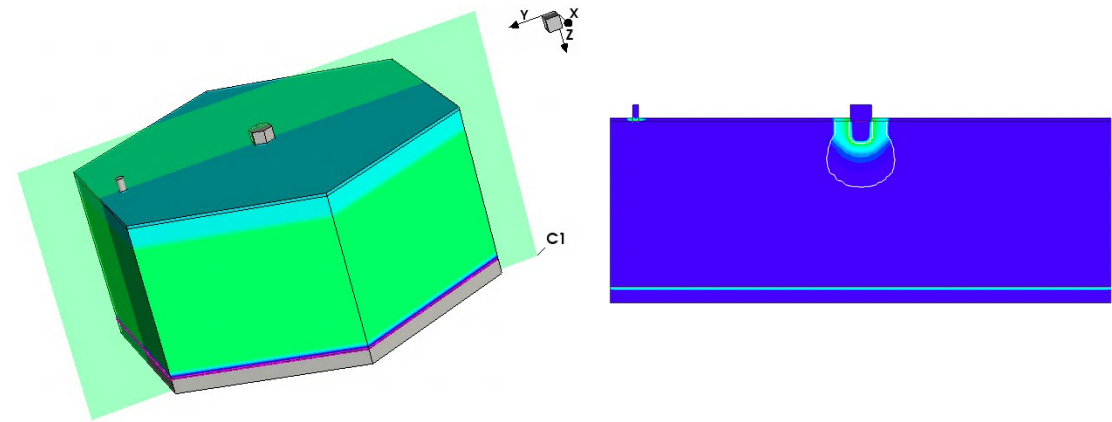


# More detail: TCAD

- Involved in several silicon sensor projects
  - Small collection electrode MAPS
  - CMOS strip sensors
  - Enhanced lateral drift sensors
- Includes investigations of electric fields, weighting fields, current densities, capacitances, ...
- Utilising Sentaurus TCAD

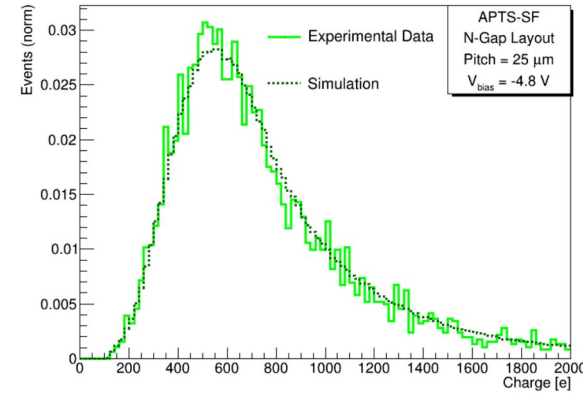


Enhanced Lateral Drift sensor simulation, [A. Velyka](#)

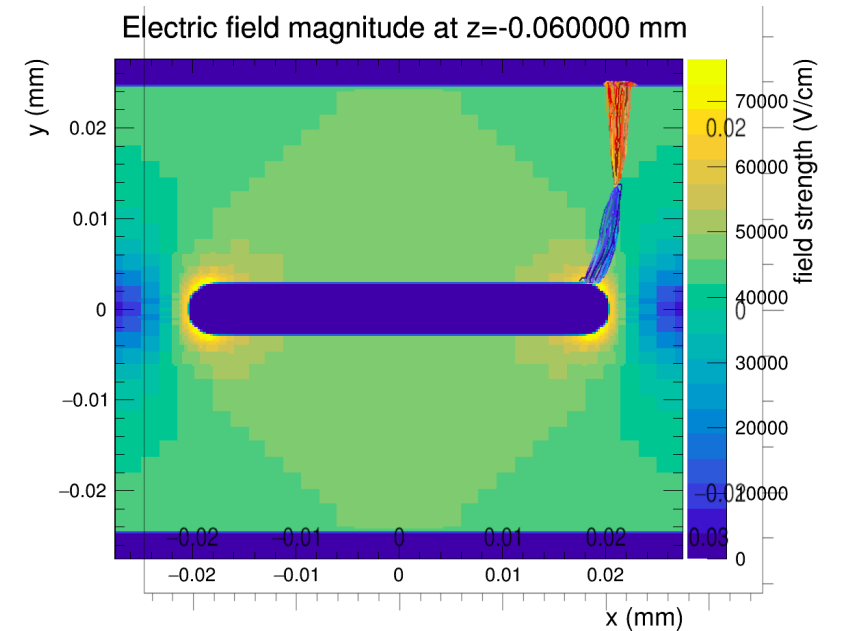
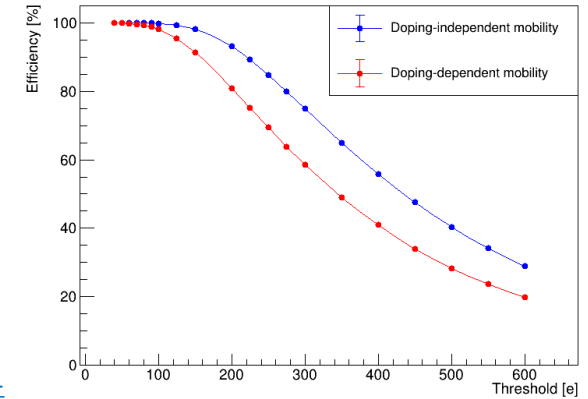


# More detail: Monte Carlo

- End-to-end simulations of thin MAPS detectors in 65 nm CIS and 180 nm CIS
  - Combined with the TCAD simulations
  - Comparing to output of prototype sensor tests
- Simulations of hexagonal pixel geometries
- Simulations of CMOS strip sensors
- Main development and maintenance of Allpix Squared
  - Impact ionisation and gain
  - 3D sensors
  - Ongoing developments:
    - High charge densities (screening and plasma effects)
    - Interfacing with front-end electronics simulation software



<https://doi.org/10.1016/j.nima.2024.169414>



# Backup slides